| Practitioner's | Docket Ne  | 104 |  |
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**PATENT** 

# IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Ted A. Loxley

Application No.: 09/490, 162

Group No.: 2812

Filed: 22 January 2000 Examiner: V. Simkovic

For: Process and Apparatus for Cleaning Silicon Wafers

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## AMENDMENT TRANSMITTAL

Transmitted herewith is an amendment for this application. 1.

#### **STATUS**

| 2. | Applicant is |                              |  |  |
|----|--------------|------------------------------|--|--|
|    | X            | a small entity. A statement: |  |  |
|    |              | ☐ is attached.               |  |  |
|    |              | was already filed.           |  |  |
|    |              | other than a small entity.   |  |  |

## CERTIFICATE OF MAILING/TRANSMISSION (37 C.F.R. § 1.8(a))

I hereby certify that this correspondence is, on the date shown below, being:

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Vincent A. Greene

(type or print name of person certifying)



### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Yicant : Ted A. Loxley

Serial No. : 09/490,162

Filed : January 22, 2000

FOR : PROCESS AND APPARATUS FOR

CLEANING SILICON WAFERS

Examiner : Viktor Simkovic - Technology Center 2800

2812

Docket No. : 104

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Amendment After Allowance Under 37 CFR 1.312

Sir:

Please amend the above-identified application by deleting the last paragraph of page 56 and replacing it with the following paragraph:

-- In the practice of the present invention electropurge cleaning with low-voltage wafer charges, such as 2 to 8
volts, can be effective with the dilute RCA and ultra-dilute RCA
(SC-1 and SC-2 cleans with or without the assistance of megasonic energy (which can be damaging to delicate nanoscale microcircuits). --